

FORM PTO-1449 (REV.7-80)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. 100096.403USPC	INT'L APPLICATION NO. PCT/SE98/01638
INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i>		APPLICANTS MATTIASSON, BO, et al.	
		INT'L FILING DATE 15 September 1998	EXPRESS MAIL NO. EL615229480US

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
CS	AA	5,500,351	03/19/96	Eccles et al.	435	25	
	AB			/			
	AC						
	AD						
	AE						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
CS	AF	EP 260 948 A2	04/02/88	EPO				X
	AG							

OTHER PRIOR ART *(Including Author, Title, Date, Pertinent Pages, Etc.)*

	AH	Abstract of EP 263 948, esp@eenet database, see also EP 260 948 A2.					
CS	AI	Henke et al., "Self-Assembled Monolayers of Monofunctionalized Cyclodextrins onto Gold: A Mass Spectrometric Characterization and Impedance Analysis of Host-Guest Interaction," <i>Anal. Chem.</i> 68:3158-3165, 1996.					
CS	AJ	Radloff et al., "Stability Improvement of an Optochemical Heavy Metal Ion Sensor by Covalent Receptor Binding," <i>Chemical Abstracts</i> 126(8):1343, Abstract No. 112425u, 1997.					
CS	AK	Radloff et al., "Stability Improvement of an Optochemical Heavy Metal Ion Sensor by Covalent Receptor Binding," <i>Sensors and Actuators B</i> 35-36:207-211, 1996.					
CS	AL	Rojas et al., "Supported Monolayers Containing Preformed Binding Sites. Synthesis and Interfacial Binding Properties of a Thiolated β -Cyclodextrin Derivative," <i>J. Am. Chem. Soc.</i> 117:336-343, 1995.					
CS	AM	Steinberg et al., "Ion-Selective Monolayer Membranes Based upon Self-Assembling Tetradentate Ligand Monolayers on Gold Electrodes. 2. Effect of Applied Potential on Ion Binding," <i>J. Am. Chem. Soc.</i> 113:5176-5182, 1991.					

EXAMINER

DATE CONSIDERED

Glen Soderquist

12/10/03

* EXAMINER: Initial if reference considered, whether or not criteria is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).